

	L #	Hits	Search Text
1	L1	111055	(mask or reticle) and (substrate or wafer)
2	L2	41262	(sampl\$3 with (shot or area))
3	L3	41262	(sampl\$3 with (shot or area))
4	L4	1215	3 same align\$4
5	L5	263	4 and 1
6	L6	420224	(distanc\$3 or interval or length) with (short\$3 or quick\$3 or minim\$4)
7	L7	89	5 and 6
8	L8	48	7 and (355/\$.ccls. or 356/\$.ccls. or 430/\$.ccls.)
9	L9	425418	(sequenc\$3 or order\$3) with (expos\$4 or process\$3)
10	L10	353409	(position\$3 or locat\$4) with (shot or area)
11	L11	7435	9 and 10 and 1
12	L12	15564	9 and 10 and 6

	L #	Hits	Search Text
13	L13	2171	1 and 12
14	L14	504	13 and (355/\$.ccls. or 356/\$.ccls. or 430/\$.ccls.)
15	L15	404	14 and align\$4
16	L16	158326	(sequenc\$3 or order\$3) with (sampl\$3 or align\$4)
17	L17	159872	15 adn 16
18	L18	194	15 and 16

QKm 3/11/03